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Subs	Substitute for form 1449A/B/PTO			Complete If Known		
				Application Number	Not Yet Assigned	
IN	FORMATI	ON DISC	LOSURE	Filing Date	Concurrently Herewith	
S	STATEMENT BY APPLICANT			First Named Inventor	Masayasu MIYATA, et al.	
				Art Unit	N/A	
	(Use as many sheets as necessary)		Examiner Name	Not Yet Assigned		
Sheet	1	of	1	Attorney Docket Number	9319A-001729/US/NP	

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Sheet 1 of 2

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APPLICANT			
Masayasu MIYATA			
FILING DATE	GROUP		
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Masayasu MIYATA	
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